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# United States Patent [19]

Anai et al.

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[54] APPARATUS FOR MANUFACTURING A SEMICONDUCTOR FOR A LIQUID CRYSTAL DISPLAY

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[73] Assignee: Tokyo Electron Limited, Tokyo, Japan

[\*\*] Term: 14 Years

[21] Appl. No.: 29/090,228

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[30] Foreign Application Priority Data

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[51] LOC (6) Cl. .... 15-09

[52] U.S. Cl. .... D15/199

[58] Field of Search ..... D15/122, 199; 257/57, 59, 66, 53, 72, 659; 349/141, 139, 43, 38, 122, 145, 146, 138; 438/162, 166, 482, 30, 149, 158, 763

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[57] CLAIM

The ornamental design for apparatus for manufacturing a semiconductor for a liquid crystal display, as shown.

DESCRIPTION

FIG. 1 is a front elevational view of apparatus for manufacturing a semiconductor for a liquid crystal display, showing our new design;

FIG. 2 is a rear elevational view thereof;

FIG. 3 is a top plan view thereof;

FIG. 4 is a left side elevational view thereof;

FIG. 5 is a right side elevational view thereof; and,

FIG. 6 is a bottom plan view thereof.

1 Claim, 2 Drawing Sheets

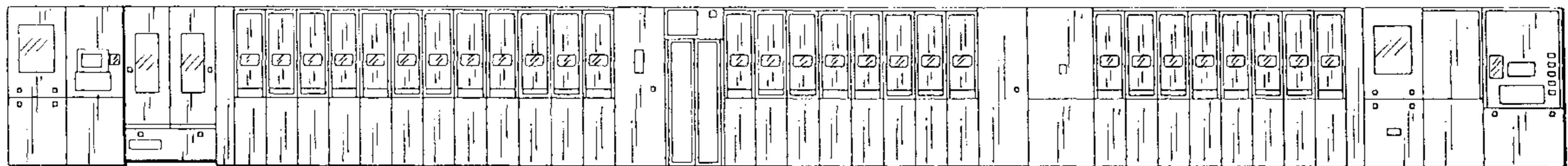


FIG.1

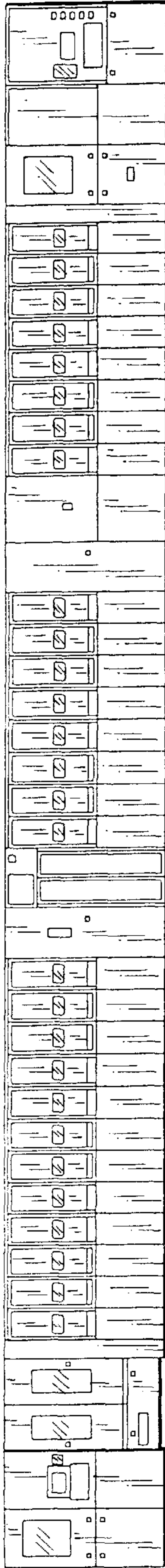


FIG.2

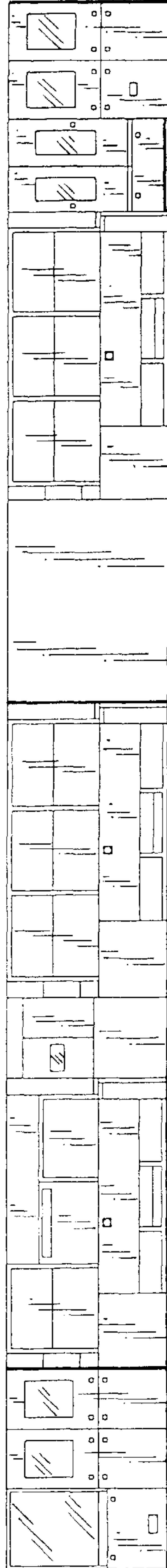


FIG.3

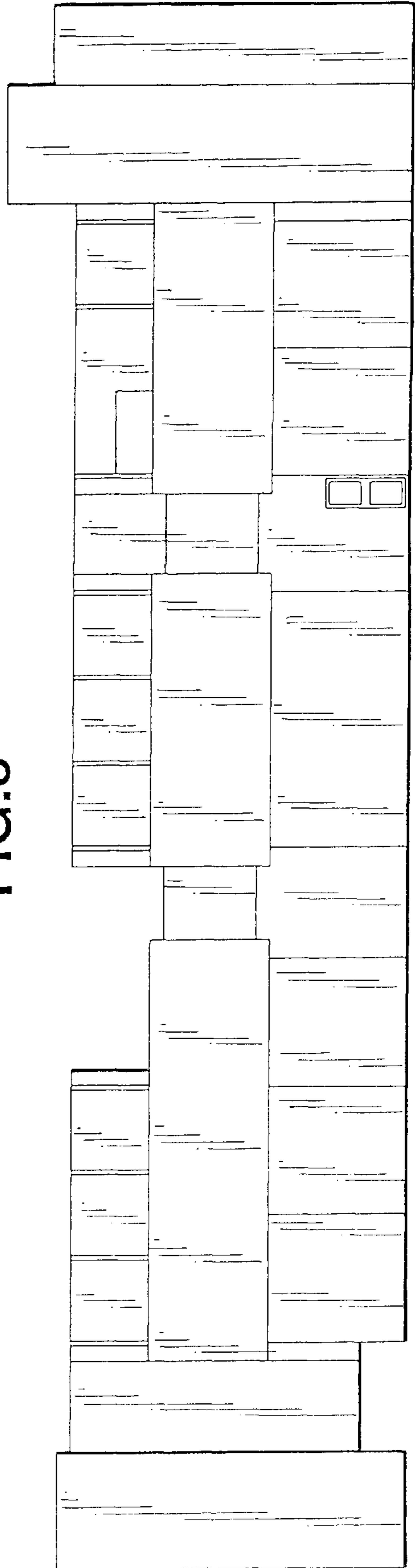


FIG.5

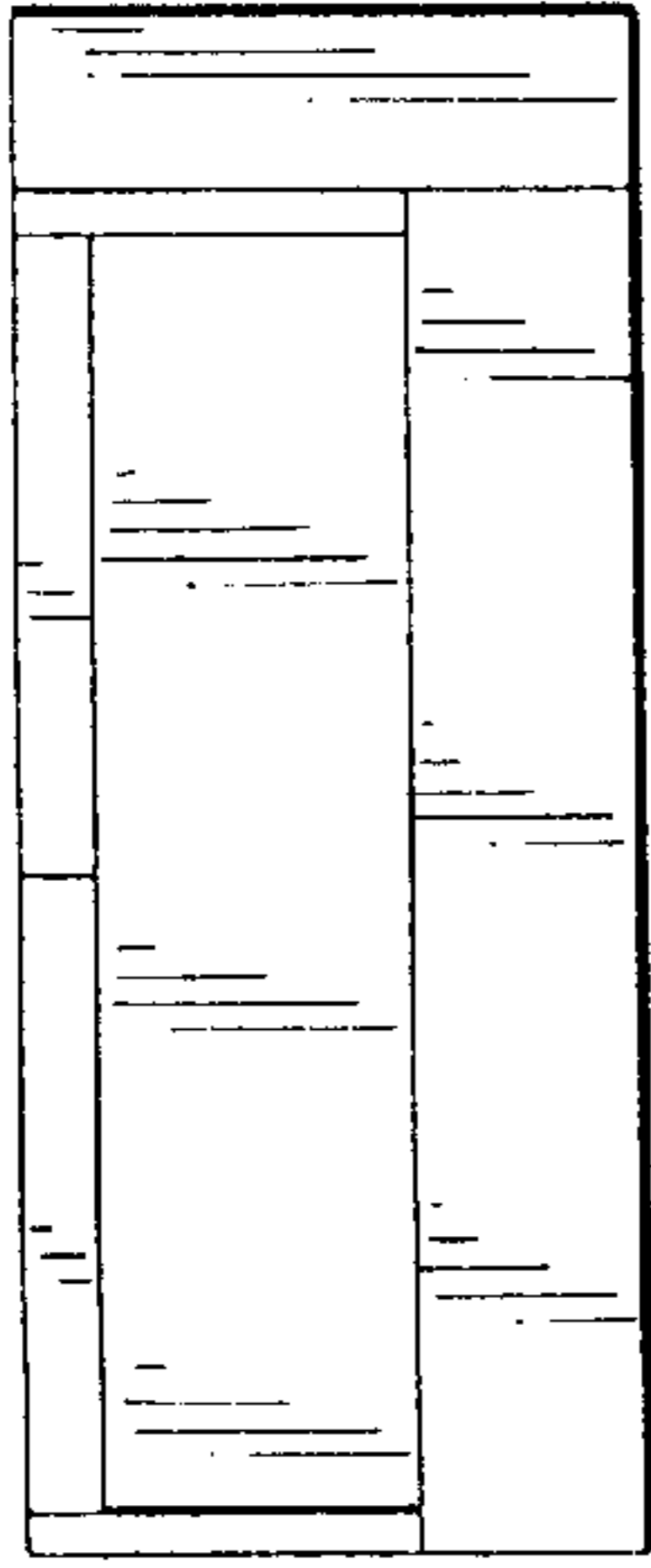


FIG.4

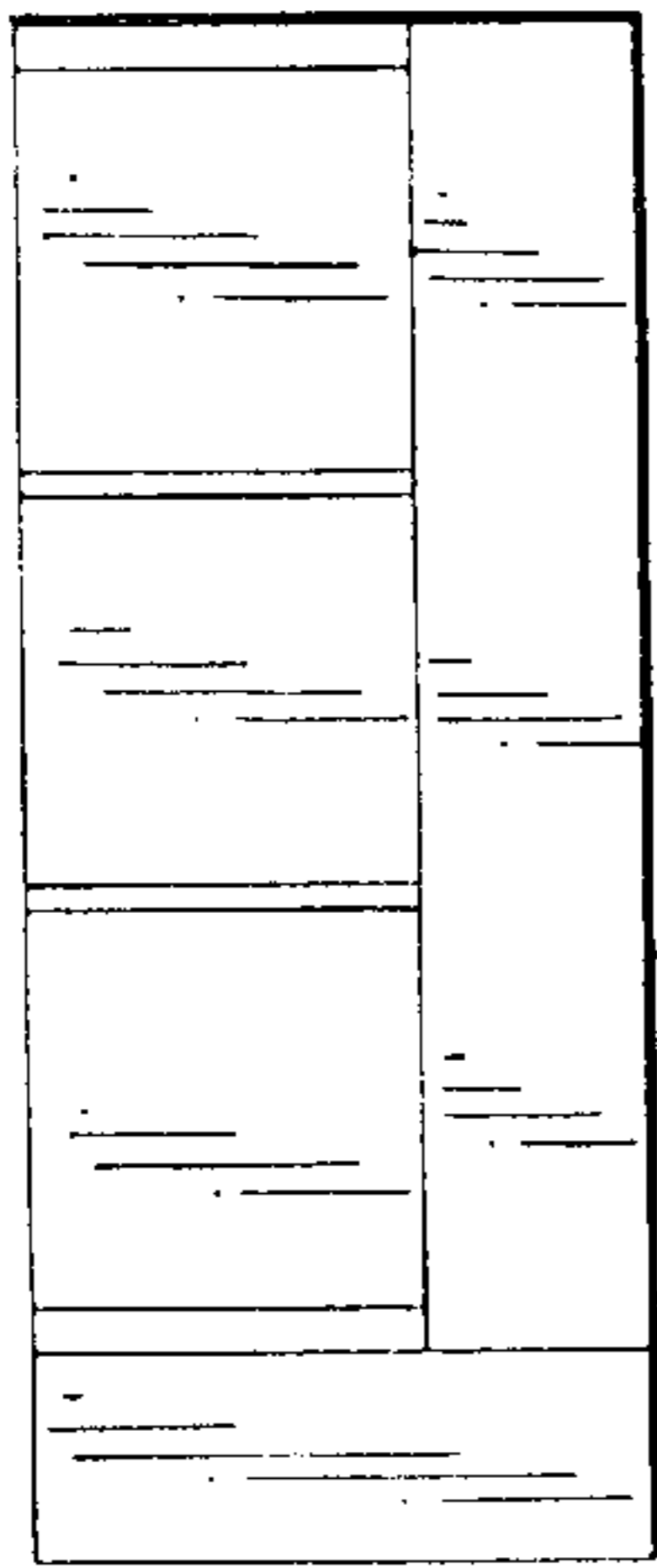


FIG.6

